

Docket No.: 4425-211

1FW 1763-  
PATENT

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of

TENG-CHUN TSAI ET AL

U.S. Patent Application No. 09/986,929

Group Art Unit: 1763

Filed: November 13, 2001

Examiner: GOUDREAU, GEORGE A.

For: METHOD OF FORMING A DUAL DAMASCENE VIA BY USING A METAL HARD MASK LAYER

Dear Sir:

Transmitted herewith is an Amendment in the above identified application.

- ☒ No additional fee is required.  
☐ Small entity status of this application has been established.  
☐ Also attached:

The fee has been calculated as shown below:

	NO. OF CLAIMS	HIGHEST PREVIOUSLY PAID FOR	EXTRA CLAIMS	RATE	FEE
Total Claims	36	36	0	x \$ 18 =	\$ 0.00
Independent Claims	3	3	0	x \$ 86 =	\$ 0.00
If multiple claims newly presented, add \$290.00					
Fee for extension of time					
TOTAL FEE DUE					\$ 0.00

- ☐ A credit card authorization form in the amount of \_\_\_\_\_ is attached
- ☒ The Commissioner is hereby authorized to charge payment of any fees associated with this communication or credit any overpayment, to Deposit Account No. 07-1337, including any filing fees under 37 CFR 1.16 for presentation of extra claims and any patent application processing fees under 37 CFR 1.17.

Respectfully submitted,

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Date: June 9, 2004  
BJH/jk



Appl. No. 09/986,929

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

**Appl. No. : 09/986,929**  
**Applicant : TENG-CHUN TSAI ET AL**  
**Filed : November 13, 2001**  
**Title : METHOD OF FORMING A DUAL DAMASCENE  
VIA BY USING A METAL HARD MASK LAYER**  
**TC/A.U. : 1763**  
**Examiner : GOUDREAU, GEORGE A**  
**Docket No. : 4425-211**

Honorable Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

**AMENDMENT**

Sir:

In response to the Official Action mailed March 10, 2004. Applicants respectfully request that the Examiner reconsider the amended application according to the following remarks.

Please amend the above-identified application as follows:

**Amendments to the Claims** are reflected in the listing of claims which begin on page 2 of this paper.

**Remarks/Arguments** begin on page 11 of this paper.